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Generic roll-to-roll compatible method for insolubilizing and stabilizing conjugated active layers based on low energy electron irradiation

Martin Helgesen, J. E. Carlé, J. Helt-Hansen, A. Miller, F. C. Krebs

Selective etching of polylactic acid in poly(styrene)-block-poly(d,l)lactide diblock copolymer for nanoscale patterning

C. Cummins, P. Mokarian-Tabari, J. D. Holmes, M. A. Morris